PATENT

FEB 1 9 204

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Kie Y. Ahn et al.

Examiner: Phuc T. Dang

Serial No.:

09/943,324

Group Art Unit: 2818

Filed:

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Docket: 303.678US3

Title:

STRUCTURE AND METHOD FOR DUAL GATE OXIDE THICKNESSE

INFORMATION DISCLOSURE STATEMENT

Box RCE

Assistant Commissioner for Patents

Washington, D.C. 20231

In compliance with the duty imposed by 37 C.F.R. § 1.56, and in accordance with 37 C.F.R. §§ 1.97 *et. seq.*, the enclosed materials are brought to the attention of the Examiner for consideration in connection with the above-identified patent application. Applicants respectfully request that this Information Disclosure Statement be entered and the documents listed on the attached Form 1449 be considered by the Examiner and made of record. Pursuant to the provisions of MPEP 609, Applicants request that a copy of the 1449 form, initialed as being considered by the Examiner, be returned to the Applicants with the next official communication.

Pursuant to 37 C.F.R. §1.97(b), it is believed that no fee or statement is required with the Information Disclosure Statement.

The Examiner is invited to contact the Applicants' Representative at the below-listed telephone number if there are any questions regarding this communication.

Respectfully submitted,

KIE Y. AHN ET AL.

By their Representatives,

SCHWEGMAN, LUNDBERG, WOESSNER & KLUTH, P.A.

P.O. Box 2938

Minneapolis, MN 55402

(612) 373-6944

Date 2//2/

By _____

David C. Peterson Reg. No. 47,857

CERTIFICATE UNDER 37 CFR 1.8. The undersigned hereby certifies that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail, in an envelope addressed to: Box RCF; Commissioner of Patents, Washington, D.C. 20231, on this 12th—day of February, 2003.

Name Amy Moriark

Signature Signature